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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: Keun-Doek Park *et al.*

SERIAL NO.: 10/607,156

EXAMINER: Daniel S. Metzmaier

FILED: June 26, 2003

ART UNIT: 1712

FOR: COLLOIDAL SILICA COMPOSITION AND PRODUCTION METHOD  
THEREOF

**AMENDMENT**

Mail Stop Amendment  
Commissioner For Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action dated August 25, 2005, the Applicant hereby requests  
amendment of the above-identified as follows: